

**CPC****COOPERATIVE PATENT CLASSIFICATION****C09G****POLISHING COMPOSITIONS OTHER THAN FRENCH POLISH; SKI WAXES****C09G 1/00****Polishing compositions** (French polish [C09F 11/00](#); detergents [C11D](#))**C09G 1/02**

- . containing abrasives or grinding agents {abrasives as such [C09K 3/14](#); polishing of semi-conductors [H01L](#)}

**C09G 1/04**

- . Aqueous dispersions ([C09G 1/02](#) takes precedence)

**C09G 1/06**

- . Other polishing compositions

**C09G 1/08**

- .. based on wax

**C09G 1/10**

- ... based on mixtures of wax and natural or synthetic resin

**C09G 1/12**

- .... mixtures of wax and silicon-containing polycondensates

**C09G 1/14**

- .. based on non-waxy substances

**C09G 1/16**

- ... on natural or synthetic resins

**C09G 1/18**

- ... on other substances

**C09G 3/00****Ski waxes**